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A QFN packaged grid array antenna in low dielectric constant LTCC for D-band applications

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Abstract — A medium-gain Grid Array Antenna (GAA) is developed and manufactured in ESL41110, a low ε_r Low Temperature Co-fired Ceramics (LTCC) from ElectroScience Laboratory. The antenna dimensions are 12 mm × 12 mm × 0.3 mm and it has a measured impedance bandwidth from 135 to 142 GHz, with a boresight maximum gain of 7.96 dBi and vertical beams. In order to realize this antenna, new LTCC fabrication steps had to be developed and qualified in the in-house procedure, including laser ablation of gold in the green state as well as after sintering.

Index Terms — D-band, Grid Array Antenna, Low Temperature Co-Fired Ceramics, LTCC, Quad Flat No-Lead Package, QFN.

I. INTRODUCTION

At the moment, the D-band frequency range 141 to 148 GHz is proposed for back-haul point-to-point relay stations and thus, several D-band Grid Array Antennas (GAA) have been developed and characterized for this purpose lately [1-6].

In some cases Liquid Cristal Polymer (LCP) is used [1] and in some cases Low temperature Co-fired Ceramics (LTCC) [2-6]. A cost benchmark on these two antennas has shown that, in small volume production, counting volumes of 500 antennas, the two solutions are very similar in cost. Comparing the two materials, LCP features low initial material cost, large processing area and is compatible with a low-cost process like wet etching. One of the drawbacks of LCP is its intrinsic softness which was resolved in [1] using a thick metal copper base of 0.5 mm. However, with this choice followed the shortcoming of the feed-through via, which could not be plated through the whole structure while at the same time not thickening the transmission line pattern on either side of the structure (antenna GAA structure on one side and a coplanar waveguide probe launch at the other side). This problem is not encountered using LTCC since the via feed-through holes are realized in each layer for the number of layers needed. One is thus within the normal fabrication routine and no special treatment is needed.

When it comes to the LTCC materials for millimeter wave devises, the most common choice is to use A6M from Ferro ($\varepsilon_r = 5.75$ and tan $\delta < 0.0023$ at 145 GHz) or 9K7 from DuPont ($\varepsilon_r = 7.1$ and tan $\delta < 0.0009$ at 10 GHz). These materials are low loss which is off course beneficial, however their relative permittivity is higher than for the ESL41110, which we have used here ($\varepsilon_r = 4.11$ and tan $\delta < 0.006$ at 110-170 GHz from our own measurements). A lower relative permittivity is advantageous to enhance the radiation of the antenna and to alleviate the line width and gap requirements as well as fabrication tolerances. However, the higher tan δ will impact the losses for the antenna feeding structure but is, for a microstrip line, somewhat counterbalanced thanks to the larger required line width, and hence, decreased metallic losses.

This paper is organized as follows; chapter II gives an overview of the design of the antenna, chapter III presents the fabrication steps and newly developed processes for the manufacturing of the antenna module and the Quad Flat No-Lead Package (QFN) package, chapter IV gives the measured results followed by a discussion and in chapter V we will conclude on this work.

II. ANTENNA DESIGN

Based on the in-house LTCC process, a QFN packaged Grid Array Antenna (GAA) is designed as shown in Fig. 1. The antenna is on the top of the package. The GAA module is flip chip mounted onto an LTCC QFN package, with a cavity to host an MMIC. Signal vias are routed through the two modules to the mother board. Thermal epoxy and vias in the QFN package, evacuates the heat from the chip back-side to the QFN heat sink. Thermal epoxy is also placed between the heat sink of the QFN package and the heat sink of the mother board. Fig. 2 shows the exploded view of the QFN package.



Fig.1. The QFN packaged GAA LTCC module overview: 3D view (left), cross section view (right).



Fig.2. The exploded view of the QFN packaged GAA. The illustration is rotated 90° .

III. FABRICATION STEPS AND SPECIAL PROCEDURES

The GAA module, built on four layers of LTCC, is manufactured in-house at Télécom Bretagne using the tape ESL41110, ESL802 gold paste for via fill and ESL803 gold paste for conductor patterning. The tape comes in sheets of 100-130 µm thickness and is compresses to 75 µm after lamination and firing. The x- and y-shrink is close to 15 %. Most fabrication procedure follows the standard LTCC steps as slanting, via hole and alignment hole cut out by laser, via conductor screen printing, inspection, stacking, fill. lamination, sintering and dicing. However, some special features were needed to process these antennas such as laser ablation of the gold on tape in green state and laser ablation of gold after sintering. The first ablation process was developed to enable a tight ground plane to via distance and the second ablation step in order to realize the small gap of 30 µm needed for the coplanar measurement probe pads. The second ablation procedure was also described in [7] and proven to work up to 170 GHz in [8].

The LTCC stack is shown in Fig. 3. where the different layers are named Lx with x denotes the number from L1 the bottom layer to Ln the top layer. In the same way, the conductor layers are named Lx_Cx and the via masks are named Lx_Vx .

After slanting and laser cutting of the vias and alignment holes, the vias on $L1_V1$, $L2_V2$, $L3_V3$ and $L4_V4$ are filled. The same print mask is used for the vias on layer $L1_V1$ to $L3_V3$, while $L4_V4$ also includes additional vias to connect

the Co-Planar Waveguide (CPW) grounds of the launch pad to the internal ground plane. Thereafter, the grid array is printed on the down side of L1, thus named $L1_C0$, since normally we print on the top side. The internal ground plane is printed as $L3_C3$ and the top feeding structure as $L4_C4$.



Fig.3. LTCC stack: GAA module (left) with antenna radiation pattern on the bottom of L1, QFN package (right).

After visual inspection the layers are stacked on an alignment fixture, sealed at the corners using Isopropanol, lifted off the alignment fixture and passed through a vacuum system to empty the air captured between layers and then stack is laminated in a uniaxial press at +70°C for 10 minutes at a pressure of 220 bars. Finally the substrates are sintered in a static oven following the profile given by the manufacturer.

The QFN package was manufactured in the same way as the GAA module; however, six layers were used for the mechanical stability of the circuit, Fig. 3. Ball bump stud bonding was used to join the two parts by flip chip assembly.

The final result, before chip assembly and joining the modules, is shown in Fig. 4.



Fig.4. Final result of the GAA module (middle column) and QFN package (right column). The two sides are shown of the modules, no chip is assembled.

A. Ablation of gold in green state tape

The antenna is fed from the backside using a metallized 180 μ m diameter via to pass the signal from the feeding side to a central point in the grid array on the radiation side. In order to fill the vias with gold paste, the screen mask is provided by a catch-pad of 230 μ m. The signal feed via passes through all four layers of the structure and through the internal ground plane which is positioned of the third tape, c.f. Fig. 3. This

ground plane serves as ground both for the antenna structure on that radiation side and to the micro-strip line on the feeding side of the structure. The ground plane is opened to not short circuit the signal feed via with a 400 µm circular opening. The distance from the catch pad to the ground plane opening is thus only 85 µm. Unfortunately we experienced some overflow of the gold during screen printing and also a misalignment between screen printing of the layers, leaving us with the result seen in the micrograph of Fig. 5. Now, to fix this, we used a micromachining station, Astree 250 from Novalase, based on a 1064 nm Nd:YAG laser. The DPSSL laser "Aion Industrial-V" has a 25 µm beam diameter which can be used to eliminate the short circuit. The laser is performing three traces, the first two distanced at 20 um apart with the following parameters: frequency=40 kHz, Power=3 W, displacement speed v=30 mm/s and repeated three times descending into the tape with 3 µm each time. These two traces will remove the printed gold. The third trace is centered between the former two, having somewhat different parameters: frequency=20 kHz, Power=4 W, displacement speed v=30mm/s and one single passage. This trace cuts into the dielectric layer making sure no short circuit remains. This way the tape is valid for further fabrication. Fig. 5 shows the initial result after screen printing and drying with the short circuit and the results after laser ablation.



Fig.5. Micrographs of ground plane; short circuited to the via (left), ablation result (right).

B. Ablation of gold after sintering

The screen printing procedure rarely allows for a line width and gaps less than 50 µm. In order to measure this antenna at the D-band we intend to use a probe station and GSG probes with 100 µm pitch from Piccoprobe. It is thus necessary to produce a coplanar probe pad with a small gap having a 50 Ω characteristic impedance. With the laser ablation parametrized to frequency=40 kHz, Power=4 W, displacement speed v=1 mm/s and repeated three times descending into the tape with 3 µm each time 25 µm wide traces are made in the sintered gold on the top surface. The middle signal line is designed to be 100 µm, the gaps are 30 µm leaving only 15 µm distance from the gap to the placement of the ground probes on the two ground pads. Since the CPW pad is DC grounded by a metallized via we arrive at a characteristic impedance of 49 Ω at 140 GHz. The laser ablated probe pad is placed on the feed side of the photograph in Fig. 6.



Fig.6. GAA antenna; feed side (left) and radiating side (right).

IV. ANTENNA MEASUREMENTS

The antenna is measured in a far-field measurement setup at Karlsruhe Institute of Technology [9]. Fig. 7 shows the reflection parameter $|S_{11}|$ of the antenna. The simulated impedance bandwidth is from 141 – 152 GHz; in measurement it ranges from 135 – 142 GHz. Fig. 8 describes the peak realized gain of the antenna. The maximum simulated gain is 9.25 dBi at 146 GHz; while in measurement it is 7.96 dBi at 142 GHz. It has vertical beams on the boresight at 141 GHz as is shown in Fig. 9. The difference between the simulated and measured antenna performance can be accounted for by fabrication tolerances such a certain misalignment between substrate layers and not correct material characteristics during the simulation ε_r =4.18 and tan δ =0.018 used instead of ε_r =4.11 and tan δ =0.006 measured later on.



Fig.7. S11 of the antenna.



Fig.8. Peak realized gain of the antenna.



Fig.9. Radiation patterns of the antenna at 141 GHz: (a) $phi = 0^{\circ}$ and (b) $phi = 90^{\circ}$.

V. CONCLUSION

In this paper, we have designed and realized a D-band QFN packaged GAA by an in-house low dielectric constant LTCC process. The GAA module shows acceptable performance and agreement between simulation and measurement. A small misalignment may count for the difference between simulated and measured results as well as a difference in the material characteristics. Future work will focus on process improvement and a complete module with chip and heat-sinks.

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